IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Huilong Zhu, et al. Examiner: Chuong A. Luu

Serial No: 10/709,239 Art Unit: 2818

Filed: April 23, 2004 Docket: FIS920030375US1 (17192)

For: STRUCTURES AND METHODS FOR Dated: April 13, 2007

MANUFACTURING OF DISLOCATION FREE STRESSED CHANNELS IN BULK SLILCON AND SOI CMOS DEVICES BY GATE STRESS ENGINEERING WITH

SiGe AND/OR Si:C

Confirmation No: 3238

Mail Stop Amendment Commissioner for Patents P.O. Box 1450

Alexandria, Virginia 22313-1450

AMENDMENT

Sir:

In connection with an Office Action issued January 17, 2007, applicants submit the following remarks for consideration by the Examiner and entry of record in the above-identified patent application.

Amendments to the Claims are provided in the Listing of Claims beginning on page 2 of this paper.

Remarks begin on page 9 of this paper.

CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on April 13, 2007.

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